

FORM PTO-1449 (MODIFIED) LIST OF PATENTS AND PUBLICATIONS FOR APPLICANTS INFORMATION DISCLOSURE STATEMENT	ATTORNEY DOCKET NO.		SERIAL NO.
	Moore 7-6C		To Be Assigned
	APPLICANT Moore et al.		
	FILING DATE Herewith		GROUP: To Be Assigned

REFERENCE DESIGNATION		U.S. PATENT DOCUMENTS					
Examiner Initial		Document Number	Date	Name	Class	Sub-Class	Filing Date if Approp.
SC	AA	1,283,333	10/29/18	Shaw			
	AB	2,188,121	1/23/40	Smith	47	78.1	
	AC	3,740,207	6/19/73	Bogrets et al.	65	67	
	AD	3,933,454	1/20/76	DeLuca	65	3	
	AE	4,221,825	9/9/80	Guerder et al.	427	34	
	AF	4,345,928	8/24/82	Kawachi et al.	65	18.2	
	AG	4,363,647	12/14/82	Bachman et al.	65	18.2	
	AH	4,612,023	9/16/86	Kreutzer et al.	65	32	
	AI	4,650,511	3/17/87	Koya et al.	65	30.1	
	AJ	4,666,495	5/19/87	Kreutzer et al.	65	258	
	AK	4,789,389	12/6/88	Schermerhorn et al.	65	31.2	
	AL	4,917,718	4/17/90	Berkey	65	108	
	AM	5,043,002	8/27/91	Dobbins et al.	65	31.2	
	AN	5,326,729	7/5/94	Yaba et al.	501	54	
	AO	5,364,433	11/15/94	Nishimura et al.	65	17.4	
	AP	5,410,428	4/25/95	Yamagata et al.	359	350	
	AQ	5,415,953	5/16/95	Alpay et al.	430	5	
	AR	5,474,589	12/12/95	Ohga et al.	65	397	
	AS	5,599,371	2/4/97	Cain et al.	65	413	
	AT	5,609,666	3/11/97	Heitmann	65	421	
	AU	5,655,046	8/5/97	Todoroki et al.	385	144	
	AV	5,683,483	11/4/97	Yosiaki et al.	65	102	
	AW	5,667,547	9/16/97	Christiansen et al.	65	17.4	
	AX	5,668,067	9/16/97	Araujo et al.	501	54	
	AY	5,679,125	10/21/97	Hiraiwa et al.	65	397	
SC	AZ	5,683,483	11/4/97	Yosiaki et al.	65	102	

EXAMINER: *A. Proasco*

DATE CONSIDERED: *4-28-04*

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REFERENCE DESIGNATION				U.S. PATENT DOCUMENTS			
Examiner Initial		Document Number	Date	Name	Class	Sub-Class	Filing Date if Approp.
AA	AA1	5,698,484	12/16/97	Maxon	501	54	
	AB1	5,702,495	12/30/97	Hiraiwa et al.	65	17.1	
	AC1	5,702,847	12/30/97	Tarumoto et al.	430	5	
	AD1	5,707,908	1/13/98	Komine et al.	501	53	
	AE1	5,735,921	4/7/98	Araujo et al.	65	32.1	
	AF1	5,764,345	6/9/98	Fladd et al.	356	35.5	
	AG1	5,837,024	11/17/98	Fabian	65	17.4	
	AK1	5,970,746	10/26/99	Fujinoki et al.	65	102	

FOREIGN PATENT DOCUMENTS								
		Document Number	Date	Country	Class	Sub-Class	Translation	
							Yes	No
AA	AA	98/27018	6/25/98	PCT	C03B	19/14	X	
	AB	98/52879	11/26/98	PCT	C03B	19/14	X	
	AC	0 401 845 A2	12/12/90	EPO	G02B	1/00	X	
	AD	0 483 752 A2	5/6/92	EPO	C03C	3/06	X	
	AE	0 488 320 A1	6/3/92	EPO	C03C	3/06	X	
	AF	0 607 433 B1	11/4/98	EPO	C03B	23/06	X	
	AG	0 636 586 A1	2/1/95	EPO	C03C	3/06	X	
	AH	0 870 737 A1	10/14/98	EPO	C03C	3/06	X	
	AI	0 901 989 A1	3/17/99	EPO	C03B	19/14	X	
	AJ	2,184,434	6/24/87	United Kingdom	C03B	20/00	X	
	AK	2,704,015 A1	8/3/78	Germany	C03B	23/04	X	
	AL	63-210044	8/31/88	Japan	C03C	17/245	X	
	AM	1-138145	5/31/89	Japan			X	
	AN	62-235223	10/15/87	Japan (abstract)	C03B	20/00		X
	AO	67/22389	11/1/67	Japan				X


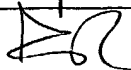
EXAMINER: *A. P. P. P.*

DATE CONSIDERED: 4/28/04

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OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

	AA	Douglas Allan, Charlene Smith, N.F. Borrelli and T. P. Seward III, <i>193-nm excimer-laser-induced densification of fused silica</i> , OPTICS LETTERS/Vol. 21, No. 24/December 15 1996, pp. 1960-1962
	AB	Roger J. Araujo, Nicholas F. Borrelli and Charlene Smith, <i>INDUCED ABSORPTION IN SILICA (A PRELIMINARY MODEL)</i> , SPIE Vol. 3424, 1998, pp. 25-32.
	AC	George H. Beall, <i>INDUSTRIAL APPLICATIONS OF SILICA</i> , Reviews in Mineralogy, 29, pp. 469-505
	AD	N.F. Borrelli, Charlene Smith, Douglas C. Allan and T.P. Seward III, <i>Densification of fused silica under 193-nm excitation</i> , J. Opt. Soc. Am B/Vol 14, No. 7/July 1997, pp. 1606-1615.
	AE	J.W. Fleming and D.L. Wood, <i>refractive index dispersion and related properties in fluorine doped silica</i> , APPLIED OPTICS/Vol. 22, No. 19/ October 1, 1983, pp.3102-3104.
	AF	David L. Griscom, <i>Optical Properties and Structure of Defects in Silica Glass</i> , The Centennial Memorial Issue, 99[10], 1991, pp. 926-942.
	AG	Hideo Hosono, Masafumi Mizuguchi, and Hiroshi Kawazoe, <i>Effects of fluorine dimer excimer laser radiation on the optical transmission and defect formation of various types of synthetic SiO₂ glasses</i> , APPLIED PHYSICS LETTERS, Vol. 74, No. 19, 10 May 1999, pp. 2755-2757.
	AH	Toshio Ibuki et al., <i>ABSORPTION SPECTRA OF SiCl₄, SiCl₆, SiF₃CH₃ AND GeF₄ IN THE VUV REGION</i> , Chemical Physics Letters, Vol. 136, No. 5, 15 May 1987, pp. 447-450.
	AI	W.D. Kingery, H.K. Brown, and D. R. Uhlmann, <i>Introduction to Ceramics, Second Edition</i> , John Wiley & Sons, 1976. pg. 654.
	AJ	M. Kyoto, Y. Ohoga, S. Ishikawa, Y. Ishiguro, <i>Research and Development Group, Sumitomo Electric Industries Ltd</i> , 1993 Chapman and Hall, pp. 2738-2744.
	AK	I. H. Malitson, <i>Interspecimen Comparison of the Refractive Index of Fused Silica</i> , Journal of the Optical Society of America, Vol. 55, No. 10, pp. 1205-1209.
	AL	James A. McClay and Angela S.L. McIntyre, <i>157 nm optical lithography: The accomplishments and the challenges</i> , Solid State Technology, June 1999, pp. 57-68.
	AM	Taro Moritani et al., "Glass Engineering Handbook," April 20, 1964, Asakura Shoten, p. 611, Clause 2.1 Fabrication.,

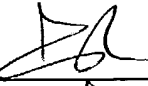

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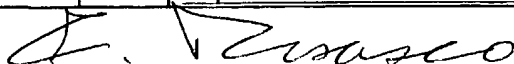
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	AN	M. Rothschild, D.J. Ehrlich & D.C. Shaver, <i>Effects Of Excimer Laser Irradiation On The Transmission, Index Of Refraction, And Density Of Ultraviolet Grade Fused Silica</i> , Appl. Phys. Lett 55(13) 9/25/99, pp. 1276-1278
	AO	Charlene M. Smith, Lisa A. Moore, <i>Fused Silica for 157 nm Transmittance</i> , SPIE Vol. 3676, 15-17 March 1999, pp. 834-841.
	AP	D.R. Sempolinski, T.P. Seward, C. Smith, N. Borrelli, C. Rosplock, <i>Effects of Glass Forming conditions on the KrF-Excimer-Laser-Induced Optical Damage In Synthetic Fused Silica</i> , Journal of Non-Crystalline Solids 203 (1996) pp. 69-77
	AQ	Richard H. Stulen & Donald W. Sweeney, <i>Extreme Ultraviolet Lithography</i> , Optics & Photonics News, August 1999, Vol. 10, No. 8, pp. 34-38
	AR	Richard E. Schenker & William G. Oldham, <i>Ultraviolet-induced Densification In Fused Silica</i> , J. Appl. Phys. 82 (3), 1 August 1997, pp. 1065-1071
	AS	Koji Tsukuma, N. Yamada, S. Kondo, K. Honda & H. Segawa, <i>Refractive Index, Dispersion and Absorption of Fluorine-Doped Silica glass in the Deep UV Region</i> , Journal of Non-Crystalline Solids 127 (1991), pp. 191-196
	AT	H. Takahashi, A. Oyobe, M. Kosuge & R. Setaka, <i>Characteristics of Fluorine-Doped Silica Glass</i> , Technical Digest: European Conference on Optical Communication, (1986) pp. 3-6
	AU	K. Tsukuma, N. Yamada, S. Kondo, K. Honda & H. Segawa, <i>Refractive Index, Dispersion and Absorption of Fluorine-Doped Silica Glass in the Deep UV Region</i> , Journal of Non-crystalline Solids 127 (1991), pp. 191-196
	AV	W. Vogel, <i>Chemistry of Glass</i> , The American Ceramic Society, Inc. (1985), pp. 203-205.
	AW	PTO: 96-0383, Journal, Title: Sheet Glass
	AX	Corning HPFS [®] , ArF Grade, Product Literature, 1999
	AY	Shin-Etsu Chemical Homepage, Semiconductor Materials Division, http://www.shinetsu.co.jp/english/profile/division/sem-div/sem-div.html , (5/17/99) pp. 1-2
	AZ	Purity and Chemical Reactivity, Isimoto Co., Ltd. Homepage, Purity and Chemical Reactivity, http://www.isimoto.com/isimoto/english/feature1.html , (5/17/99) pp. 1-3

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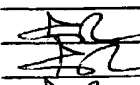
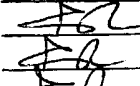

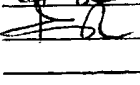
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	AL	0 878 451 A1	11/18/98	EPC				
	AM	0 835 848 A2	4/15/98	EPC				
	AN	08-067530	3/12/96	JAP			X	
	AO	07-291635	11/7/95	JAP			X	
	AP							
	AQ							

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

	AA1		Products for Optics, Isimoto Co., Ltd. Homepage, http://www.isimoto.com/isimoto/english/variation 3.html , (5/17/99) pp. 1-2
	AB1		Product Information, Isimoto Co., Ltd. Homepage, http://www.isimoto.com/isimoto/english/product info.html , (5/17/99) pp. 1-4

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